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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 4981
Hiroshi TAKANASHI et al. : Docket No. 2000-1749
Serial No. 09/739,750 : Group Art Unit 1752
Filed December 20, 2000 : Examiner S. Lee
NEGATIVE-WORKING PHOTOSENSITIVE :
RESIN COMPOSITION AND PHOTOSENSITIVE
RESIN PLATE USING THE SAME

13/12

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Petition hereby is made for a five month extension of time to file an Appeal Brief in connection with the Notice of Appeal filed on December 19, 2003.

The fee of \$1,970.00 is

(X) submitted herewith.
() to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.

() Small entity status of this application is established by a Small Entity Status Assertion which

() is enclosed.
() has been previously submitted.

07/22/2003 KZEWIDIE 00000031 09739750

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1970.00 GP

Respectfully submitted,

Hiroshi TAKANASHI et al.

By

Matthew Jacob
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July 21, 2003